

Notic of References Cited

Application/Control No.

09/878,265

Applicant(s)/Patent Under
Reexamination
OGURA ET AL.

Examiner

Alvin J Grant

Art Unit

3723

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*		Document Number Country Code-Number-Kind Code	Date MM-YYYY	Name	Classification
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NON-PATENT DOCUMENTS

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*A copy of this reference is not being furnished with this Office action. (See MPEP § 707.05(a).)
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